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(12) **United States Design Patent**  
**Park**

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(54) **NAIL POLISH APPLIQUÉ STRIP**

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(\*\*) Term: **14 Years**

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(52) **U.S. Cl.**  
USPC ..... **D28/56**

(58) **Field of Classification Search**  
USPC ..... 132/200, 73, 73.5, 285, 74.5; D28/56;  
D20/11  
See application file for complete search history.

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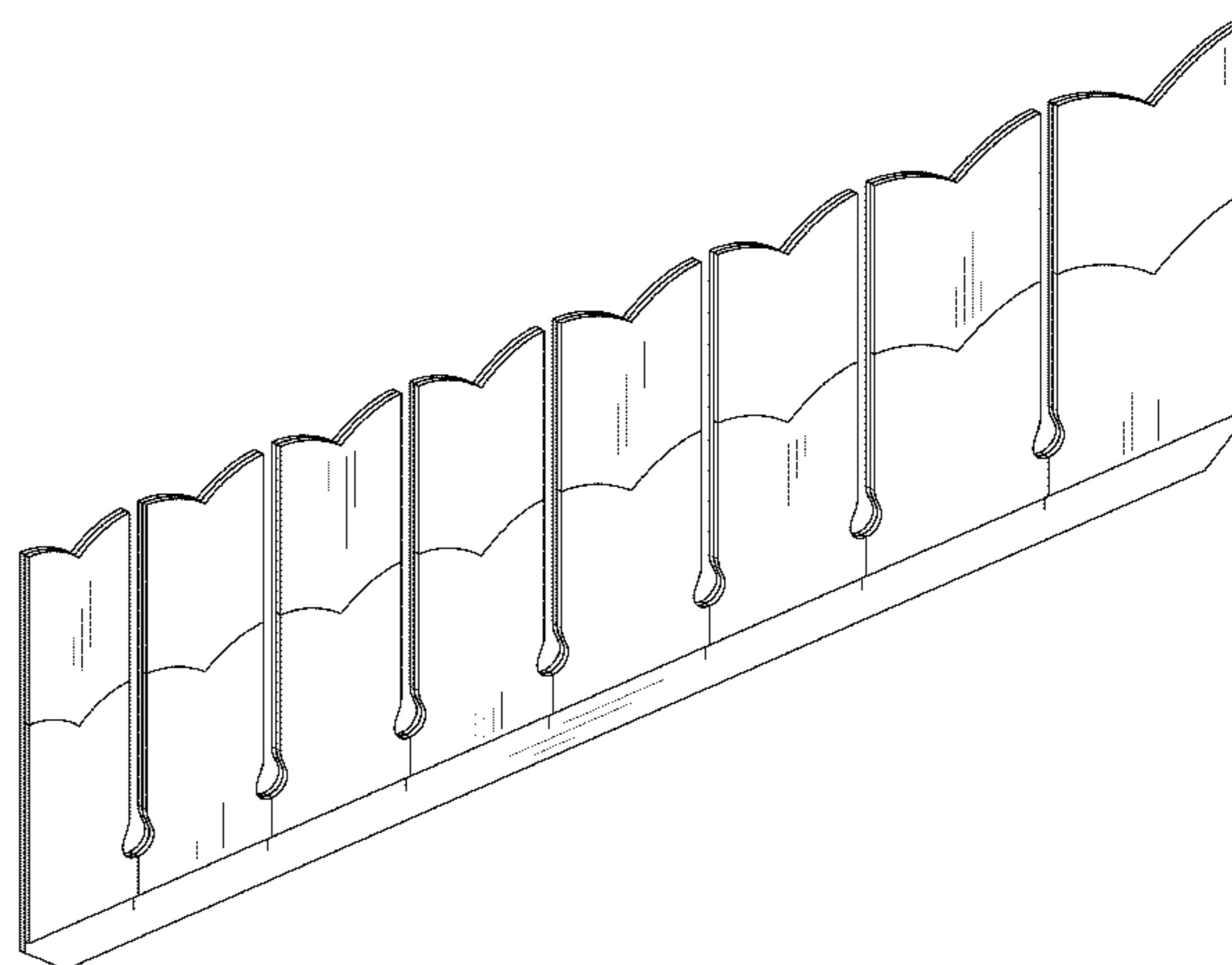
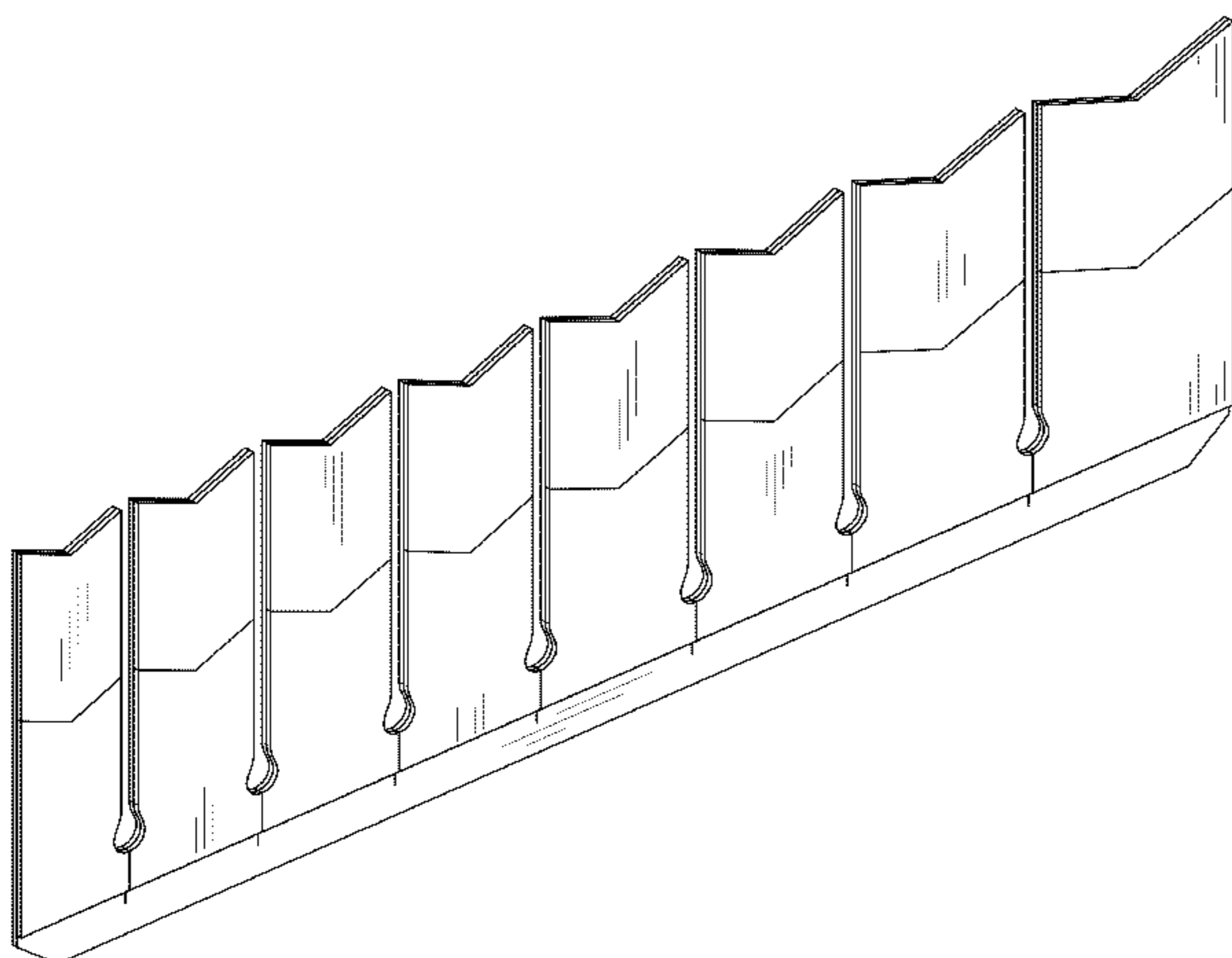
(57) **CLAIM**

The ornamental design for a nail polish appliqué strip, as shown.

**DESCRIPTION**

FIG. 1 is a perspective view of a nail polish appliqué strip showing a first embodiment of my new design;  
 FIG. 2 is a front elevational view of the nail polish appliqué strip shown in FIG. 1;  
 FIG. 3 is a rear elevational view of the nail polish appliqué strip shown in FIG. 1;  
 FIG. 4 is a right side elevational view of the nail polish appliqué strip shown in FIG. 1;  
 FIG. 5 is a left side elevational view of the nail polish appliqué strip shown in FIG. 1;  
 FIG. 6 is a top plan view of the nail polish appliqué strip shown in FIG. 1;  
 FIG. 7 is a bottom plan view of the nail polish appliqué strip shown in FIG. 1;  
 FIG. 8 is a perspective view of a nail polish appliqué strip showing a second embodiment of my new design;  
 FIG. 9 is a front elevational view of the nail polish appliqué strip shown in FIG. 8;  
 FIG. 10 is a rear elevational view of the nail polish appliqué strip shown in FIG. 8;  
 FIG. 11 is a right side elevational view of the nail polish appliqué strip shown in FIG. 8;  
 FIG. 12 is a left side elevational view of the appliqué strip shown in FIG. 8;  
 FIG. 13 is a top plan view of the nail polish appliqué strip shown in FIG. 8; and,  
 FIG. 14 is a bottom plan view of the nail polish appliqué strip shown in FIG. 8.

**1 Claim, 6 Drawing Sheets**



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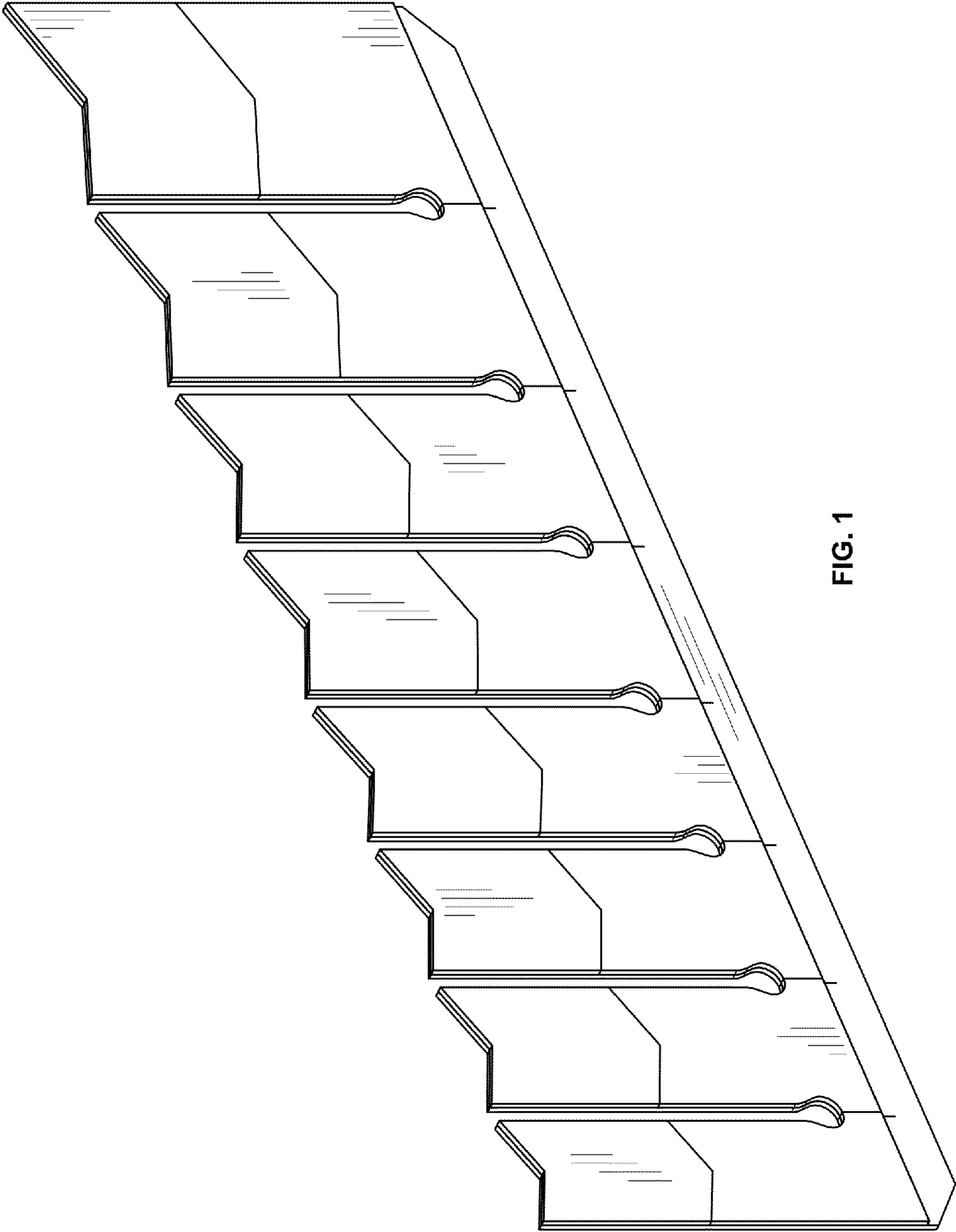


FIG. 1

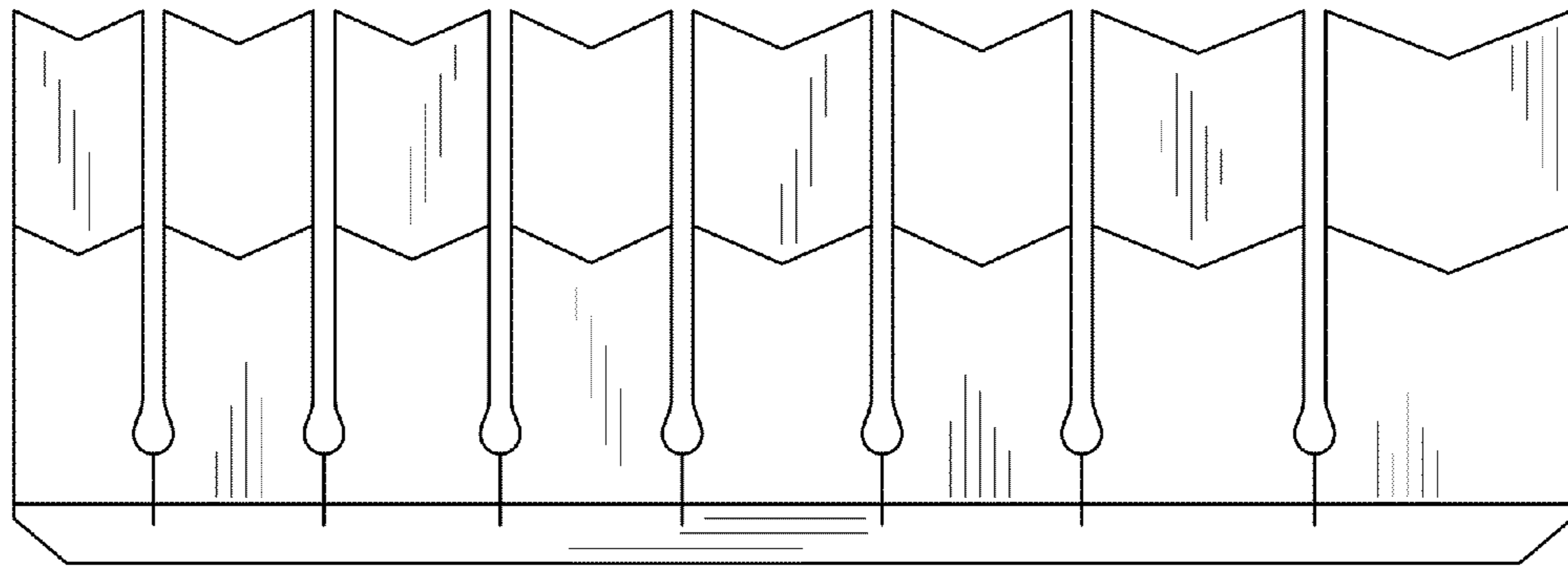


FIG. 2

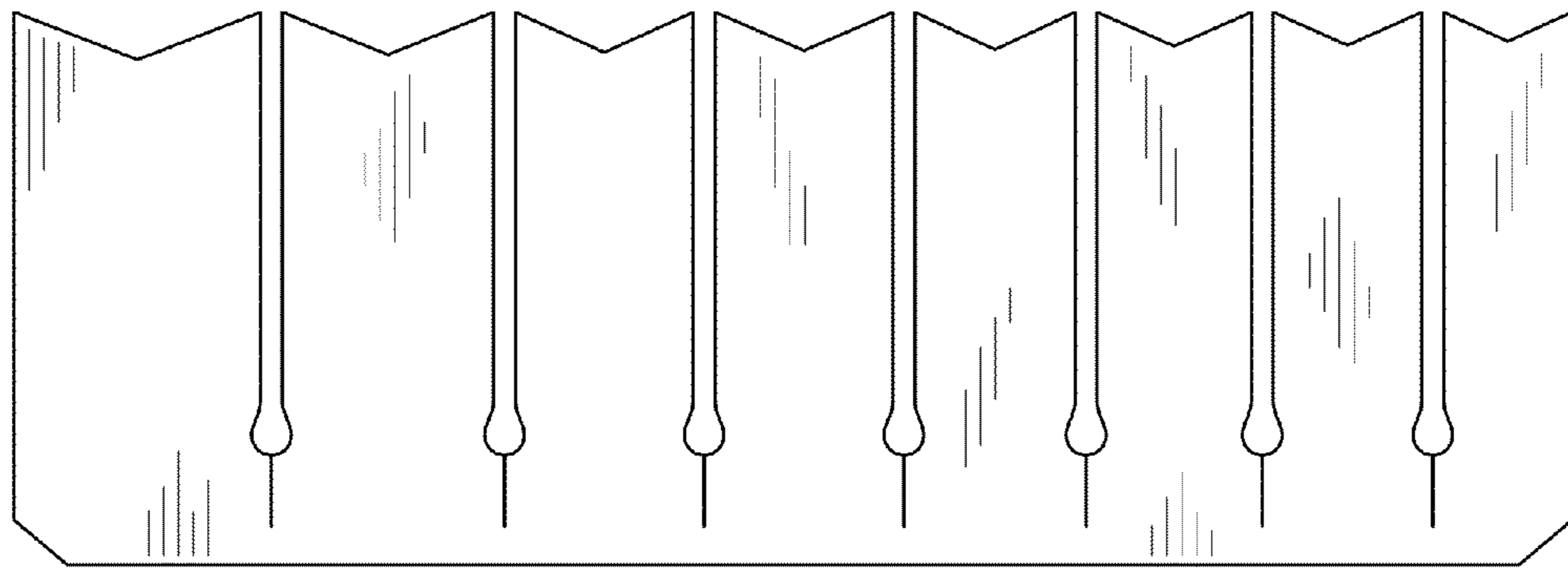


FIG. 3



FIG. 4



FIG. 5



FIG. 6



FIG. 7

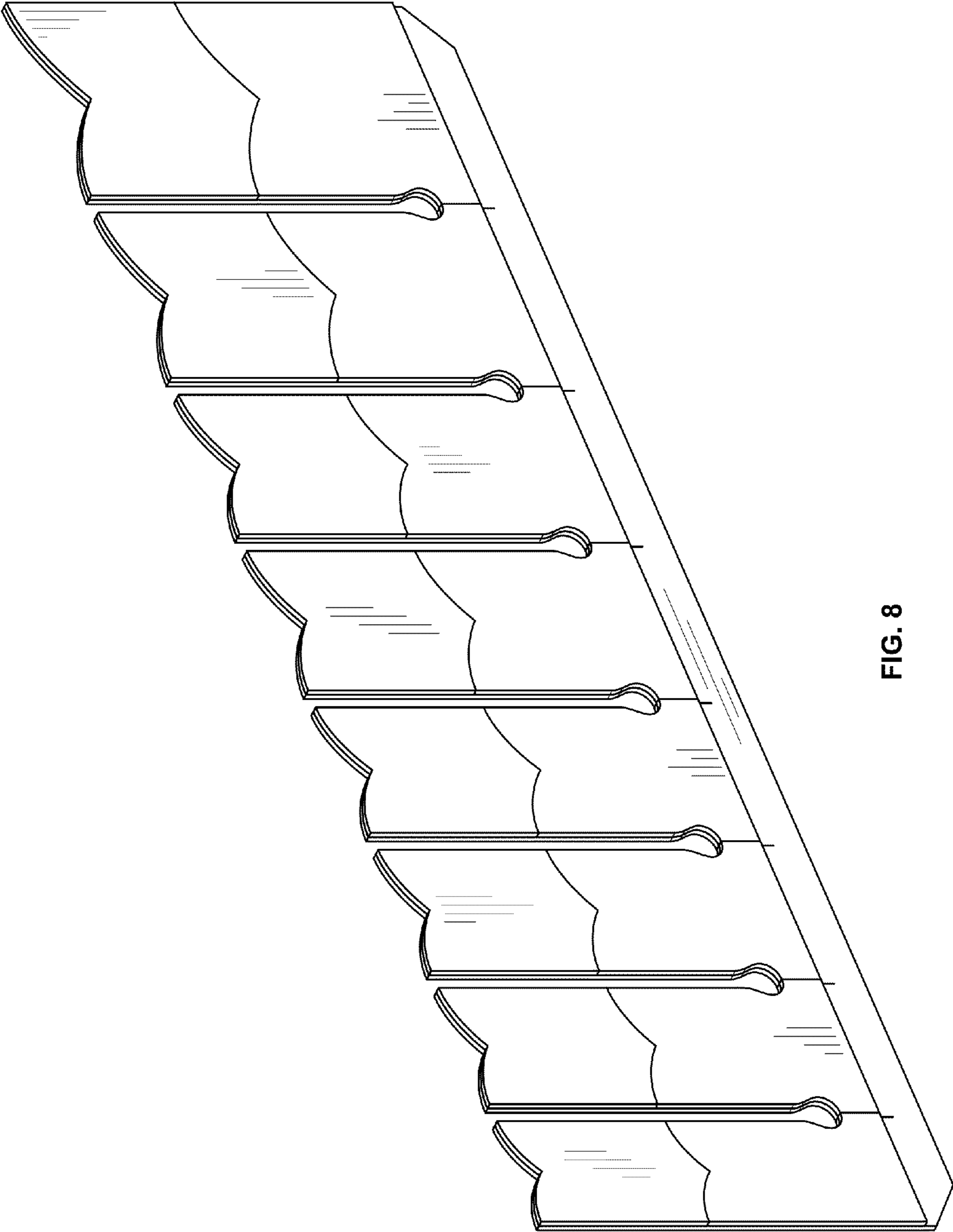


FIG. 8



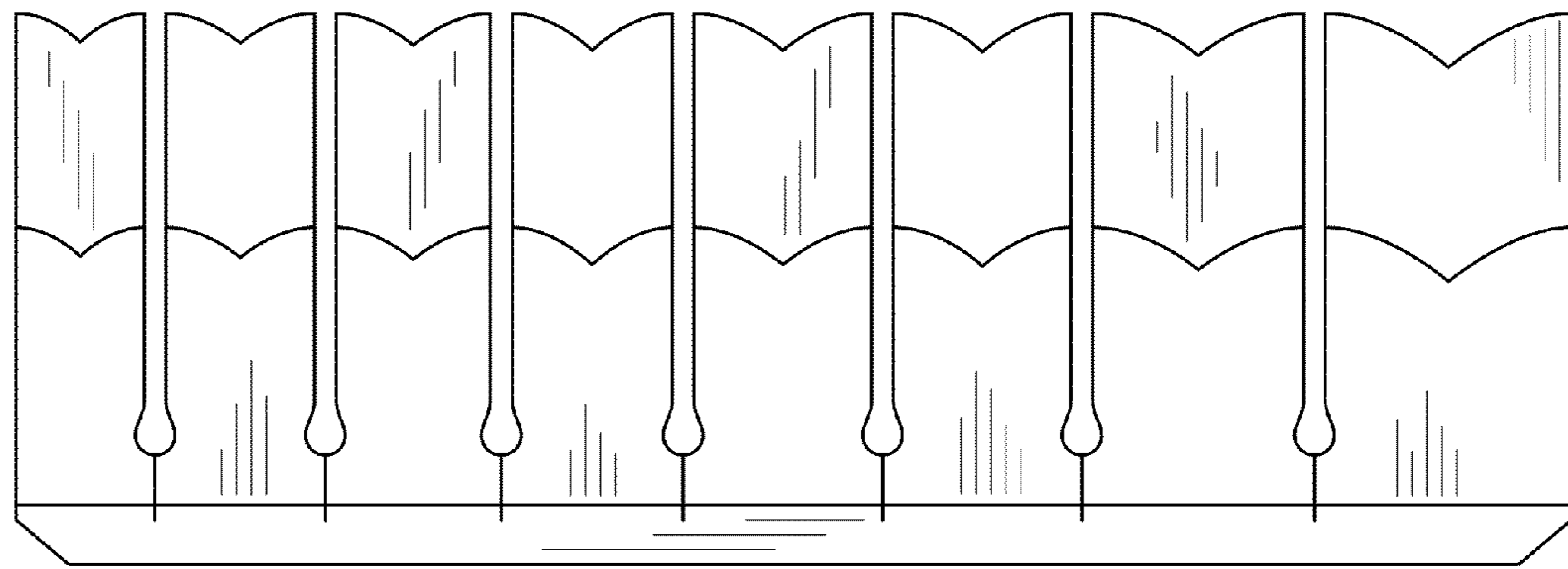


FIG. 9

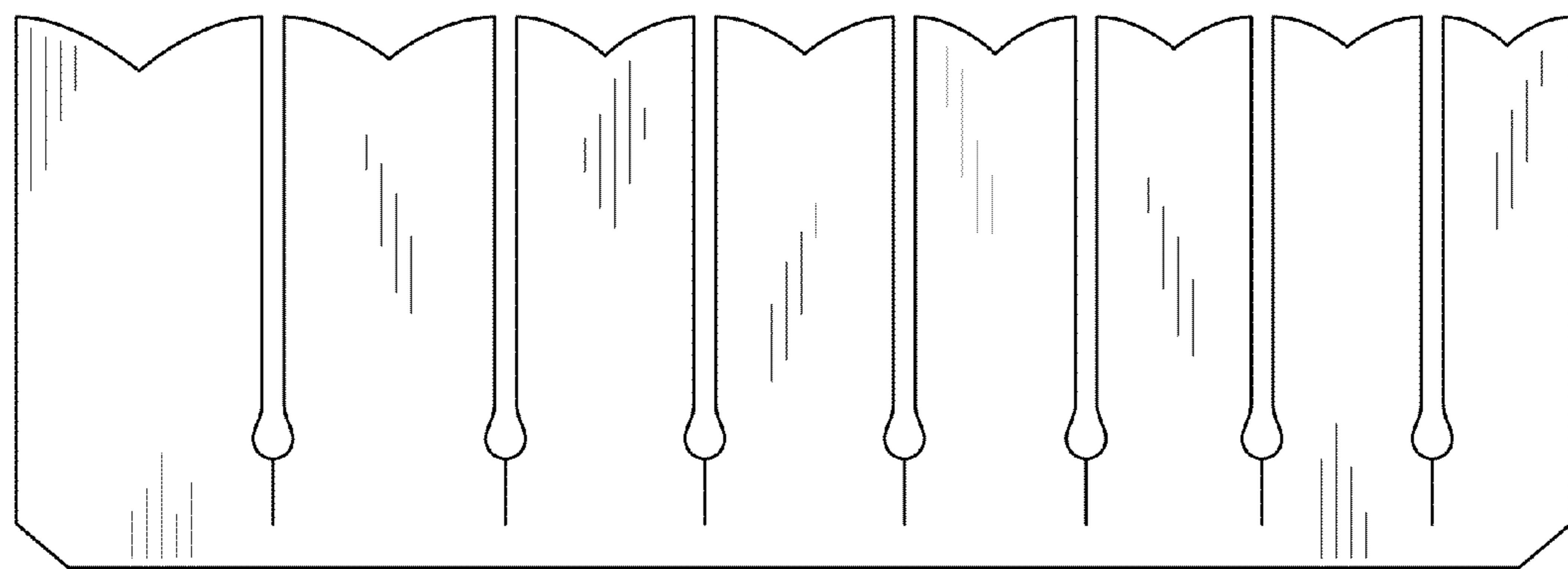


FIG. 10



FIG. 11



FIG. 12

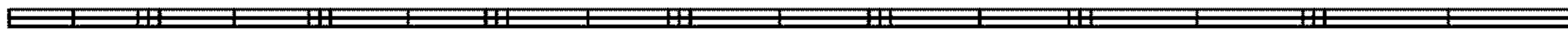


FIG. 13

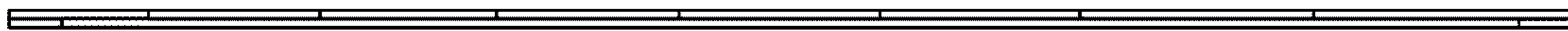


FIG. 14